

DuPont Kalrez® 9100

For PECVD/ALD/HCPCVD & Conductor Etch Applications

Technical Information - March, 2017

Product Description

DuPont Kalrez® 9100 is an amorphous fluoropolymer (aFEP) specifically for PECVD, ALD, HCPCVD and Conductor (Phosphor) Etch applications. Kalrez® 9100 has been specifically designed for low erosion and ultra-low particle generation in harsh plasma environments. It offers excellent thermal stability, very low outgassing as well as excellent etch recovery and good mechanical strength properties and is well suited for both static and select dynamic testing applications. A maximum application temperature of 300°C (572°F) is suggested. Ultrasonic post-cleaning and packaging is standard for all Kalrez® 9100 parts.



Features/Benefits

- Low erosion rate and ultra-low particle generation in oxygen and fluorine-based plasmas
- Excellent resistance to dry process chemistry
- Excellent thermal stability
- Very low outgassing properties and metals content
- Excellent etch recovery and low compression set properties

Suggested Applications

- Gas distribution nozzles
- Chamber fit nozzles
- Isolation valve seats
- Substrates: bonded gate valves/fit isolation seats*

Typical Physical Properties*

| | meter |
|---|--------------|
| Color | Translucent |
| Hardness, Shore D ¹ (23°C/73°F) | 70 |
| Hardness, Shore M ² (23°C/73°F) | 70 |
| 100% Modulus ³ , MPa (psi) | 5.17 (750) |
| Tensile Strength at Break ⁴ , MPa (psi) | 15.67 (2275) |
| Elongation at Break ⁴ , % | 280 |
| Compression Set ⁵ , % | |
| 70 h, at 204°C (397°F) | 18 |
| 70 h, at 300°C (572°F) | 21 |
| 70 h, at 300°C (572°F) | 58 |
| Max. Application Temperature ⁶ , °C (°F) | 300 (572) |

*Values are typical values for a standard product.
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*Values are for a standard application design to assess performance for your specific application.



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